Art Unit: 1765

Examiner:

L. Umez Eronini

## RECEIVED CENTRAL FAX CENTER

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE SEP 2 0 2007

Applicant(s): Wang

Application No.: 10/723,746

Filed: 11/25/2003

Title: POLISHING COMPOSITION FOR CMP

HAVING ABRASIVE PARTICLES

HAVING ABRASIVE PARTICLES

Attorney Docket No.: 03049US

Commissioner for Patents P.O. Box 1450

Alexandria, VA 22313-1450

## RESPONSE

Dear Sir:

In response to the Office Action of May 3, 2006, having a shortened statutory deadline extended by the petition to revive, please amend this application as follows: